



Docket No.: M4065.0319/P319
(PATENT)

41/H
9/30/03 (N-E)
Adm H

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:
Ronald A. Weimer, et al.

Application No.: 09/296,835

Group Art Unit: 2813

Filed: April 22, 1999

Examiner: Erik J. Kielin

For: FABRICATION OF DRAM AND OTHER
SEMICONDUCTOR DEVICES WITH AN
INSULATING FILM USING A WET RAPID
THERMAL OXIDATION PROCESS

AMENDMENT

U.S. Patent and Trademark Office
2011 South Clark Place
Customer Window
Crystal Plaza Two, Lobby, Room 1B03
Arlington, VA 22202

Dear Sir:

Responsive to the Office Action dated June 18, 2003, please amend the above-captioned U.S. Patent application as follows:

RECEIVED
SEP 25 2003
TECHNOLOGY CENTER 2300